

Journal of
Photochemistry
and
Photobiology
A: Chemistry

Volume 159 (2003)

Editor-in-Chief

R. P. Wayne
(Oxford, UK)

Associate Editors

J. D. Coyle
(Oxford, UK)
N.S. Allen
(Manchester, UK)

North American Editor

R. Schmechl
(New Orleans, LA, USA)

Asian Editor

H. Masuhara
(Osaka, Japan)

Editorial Board

A. U. Acuña (Madrid, Spain)
R. A. Caldwell (Richardson, TX, USA)
J. Delaire (Cachan Cedex, France)
D. F. Eaton (Wilmington, DE, USA)
S. J. Formosinho (Coimbra, Portugal)
H. Fukumura (Sendai, Japan)
K. Ghiggino (Melbourne, Australia)
C. E. Hoyle (Hattiesburg, MS, USA)
D. Husain (Cambridge, UK)
H. Inoue (Tokyo, Japan)
M. Irie (Fukuoka, Japan)
E. Lissi (Santiago, Chile)
B. Marciniak (Poznań, Poland)
U. Mazzucato (Perugia, Italy)
T. J. Meyer (Los Alamos, NM, USA)
A. Mills (Glasgow, UK)
D. C. Neckers (Bowling Green, OH, USA)
B. Ohtani (Sapporo, Japan)
D. Phillips (London, UK)
J. C. Polanyi (Toronto, Ont., Canada)
G. Poulet (Orleans cedex 2, France)
I. Saito (Kyoto, Japan)
J. C. Scaiano (Ottawa, Ont., Canada)
R.P. Steer (Saskatoon, Sask., Canada)
N. J. Turro (New York, NY, USA)



ELSEVIER

AMSTERDAM-LONDON-NEW YORK-OXFORD-PARIS-SHANNON-TOKYO